

European Network on New Sensing Technologies for Air Pollution Control and Environmental Sustainability - *EuNetAir*

COST Action TD1105

INTERNATIONAL WG1-WG4 MEETING on

New Sensing Technologies and Methods for Air-Pollution Monitoring

European Environment Agency - EEA

Copenhagen, Denmark, 3 - 4 October 2013

Action Start date: 01/07/2012 - Action End date: 30/06/2016 - Year 2: 2013-2014 (*Ongoing Action*)

Low-Cost Metal Oxides Gas Sensors: State of Art, Perspectives and New Challenges

(New nanomaterials and processes for fully integrated all-solid state reliable gas sensor on micro machined platforms: conductometric, surface ionization and electrochemical sensor types)



J. R. Morante

WG1 Leader

IREC Catalanian Institute for Energy Research

Barcelona, Spain

Scientific context and objectives

- **Background / Problem statement:**

Since 1962 it has been known that metal oxide thin films interact with gaseous components from the surrounding ambient [1]. “A new detector for gaseous components using semiconductor thin films”

The main consequence of this interaction is modification of their electrical characteristics and, consequently, it can be used as the basis for gas detector development. A great deal of effort has been made to improve the knowledge and understanding of the related processes.

During the last 50 years many critical issues related with the sensing phenomena and performances have been analyzed and studied and it is corresponding to the history of solid state metal oxide based gas sensors:

the interaction of the metal oxide surface with oxygen and water [2],

the effects of the additives [3],

the role played for catalysts [4, 5],

the significance of the grain size [6],

the modeling of the sensor response laws [7, 8], etc

[1] Seiyama T, Kato A, Fujiishi K and Nagatani M 1962 Anal. Chem. 34 1502

[2] Yamazoe N, Fuchigami J, Kishikawa M and Seiyama T 1979 Surf. Sci. 86 335

[3] Yamazoe N, Kurokawa Y and Seiyama T 1983 Sensors Actuators B 4 283

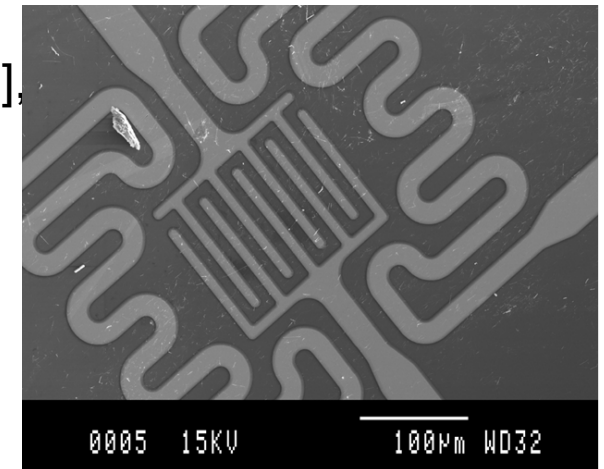
[4] Iwamoto M, Yoda Y, Egashira M and Seiyama T 1976 J. Phys. Chem. 80 1989

[5] Seiyama T, Yamazoe N and Eguchi K 1985 Indust. Eng.Chem. Prod. Res. Dev. 24 19

[6] Xu C N, Tamaki J, Miura N and Yamazoe N 1991 Sensors Actuators B 3 147

[7] Yamazoe N and Shimano K 2008 Sensors Actuators B 128 566

[8] Yamazoe N and Shimano K 2011 Sensors Actuators B 158 285



Scientific context and objectives

- **Background / Problem statement:**

Nevertheless, in spite of the growing commercial success [9–15], keeping low cost, many basic issues still remain open and under discussion, limiting the broad use of this technology.

[9] www.figarosensor.com/

[10] www.fisinc.co.jp/

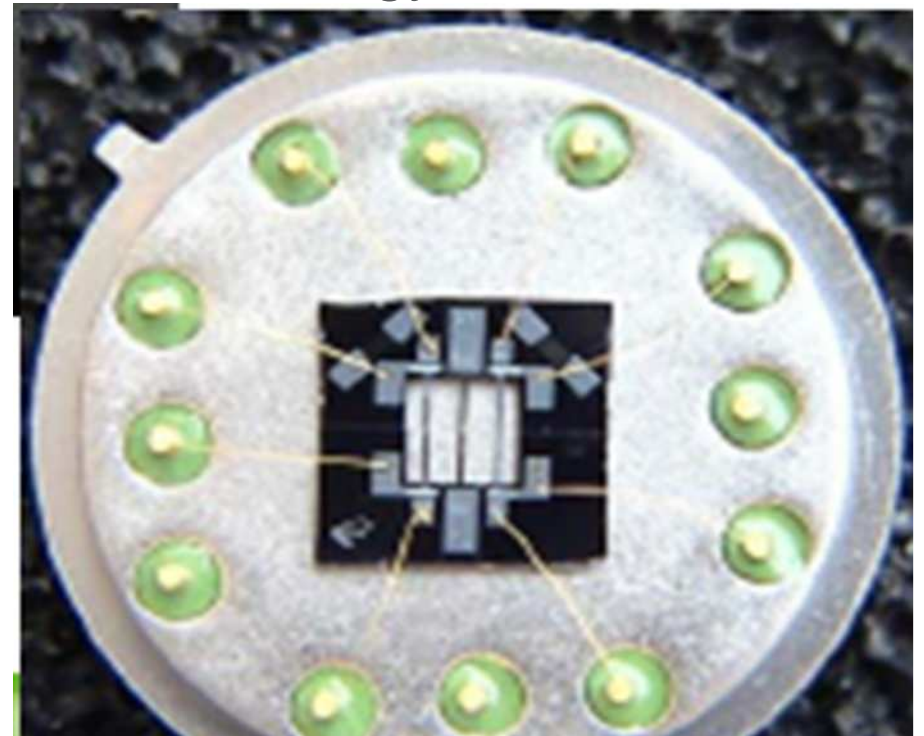
[11] www.alphasense.com/

[12] www.alpha-mos.com/

[13] www.appliedsensor.com/

[14] www.e2v.com/

[15] www.umweltsensortechnik.de/



Scientific context and objectives

- Background / Problem statement:**

Commercial solid state gas sensors are currently based on thin/thick layers or micro bead of metal oxide semiconductors deposited onto heaters platform, which are used to control the temperature at the optimal values to activate the surface transduction mechanisms.



TH (H)	Heating time (high)	5 sec ± 0.1 sec	
TH (L)	Heating time (low)	20 sec ± 0.1 sec	
I _s (H)	Current consumption (high)	132mA ± 15mA	V _H =0.9V
I _s (L)	Current consumption (low)	59mA ± 10mA	V _H =0.2V
P _s	Power dissipation	Less than 10 mW	

Heater voltage cycle	V _H	V _{HH} =4.8V±0.2V DC, 14ms V _{HL} =0.0, 986ms	Heater Voltage	V _H	V _{HH} = 0.9V±3%, 5 sec. V _{HL} = 0.2V±3%, 15 sec.	
Circuit voltage cycle	V _C	V _C =0V for 995ms, V _C =5.0V±0.2V DC for 5ms	Circuit voltage	V _C	5.0±0.2V DC pulse <i>(refer to Technical Information for TGS3870)</i>	
Load resistance	R _L	variable (≥10kΩ)	Load resistance	R _L	Variable (>0.75kΩ)	
Heater resistance	R _H	17 ± 2.5Ω at room temp.	Heater resistance	R _H	3±0.3Ω at room temp.	
Heater current	I _H	approx. 203mA(In case of V _{HH})	Heater power consumption	P _H	120mW	V _{HH} = 0.9V DC
Heater power consumption	P _H	approx. 14mW (ave.)			11mW	V _{HL} = 0.2V DC
					38mW	average

Scientific context and objectives

- Background / Problem statement: Reliable for large market but expensive

- » Home
- » Company Profile
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- » Products
 - » Carbon Dioxide Sensors
 - » NDIR Sensors
 - » Carbon Monoxide B4
 - » Hydrogen Sulfide B4
 - » Nitric Oxide B4
 - » Nitrogen Dioxide B4
 - » Sulfur Dioxide B4
 - » Ozone B4
 - » Optical Particle Counter
 - » PID Sensors
 - » Integrated Sensor Boards
- » Downloads
- » Links
- » Industrial

» Carbon Monoxide 4-Electrode Sensor



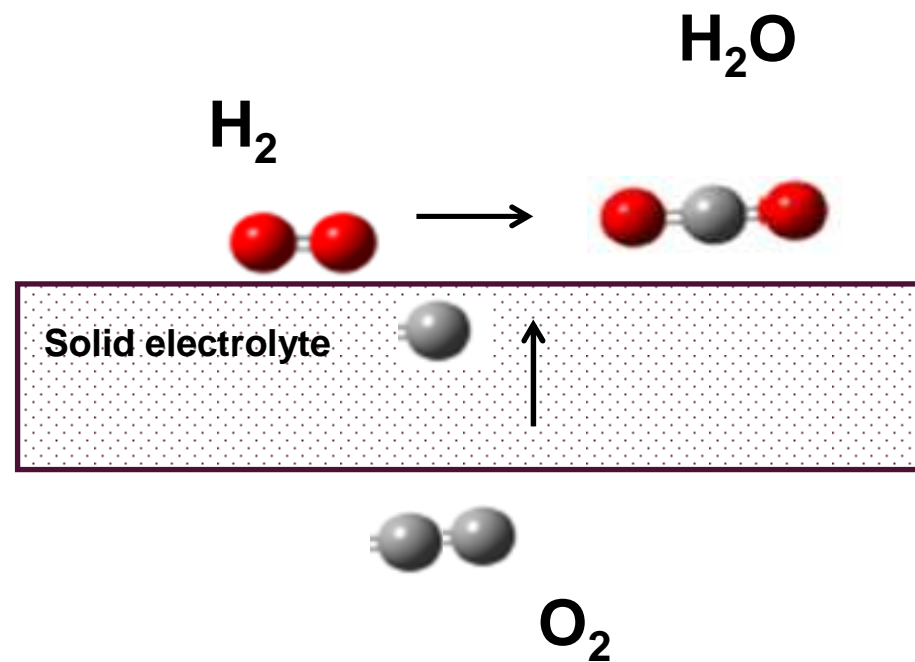
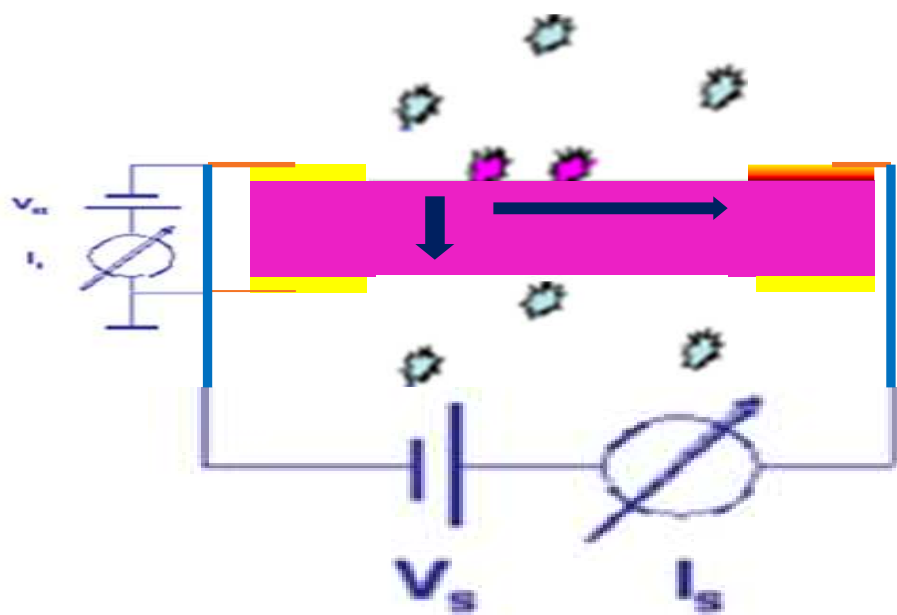
Alphasense 4-Electrode gas sensors operate using proven fuel cell technology.

The B4 series (4-electrode sensors) provides OEMs with reliable sensors for use in a number of high volume applications and especially Air Quality Networks where very low parts per billion (ppb) detection levels are required. Strong signal levels combined with low zero current allows resolution to < 10 (ppb) and a wide operating range. The sensors are suitable for use in fixed installation sensing heads, portable safety instruments, urban/indoor air monitoring and stack gas analysers.

The B4 series of sensors offer our electrolyte leak-free guarantee and reliable long-term detection performance. The leak-proof housing is moulded with a colour coded top for ease of identification.

Alphasense tests the performance of every sensor; results are stored on our database, giving full traceability for all sensors. The unique Automatic Test and Validation (ATAV) system controls initial sensor stabilisation and runs complex tests under computer control. This computerised system also ensures traceability as tested sensors are moved direct to despatch with their unique barcodes. The ATAV system also

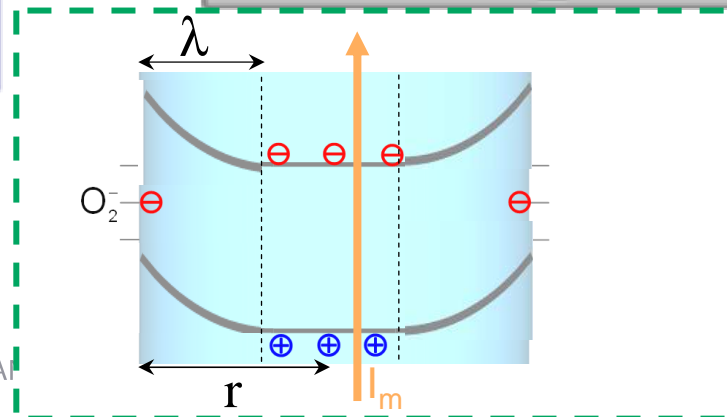
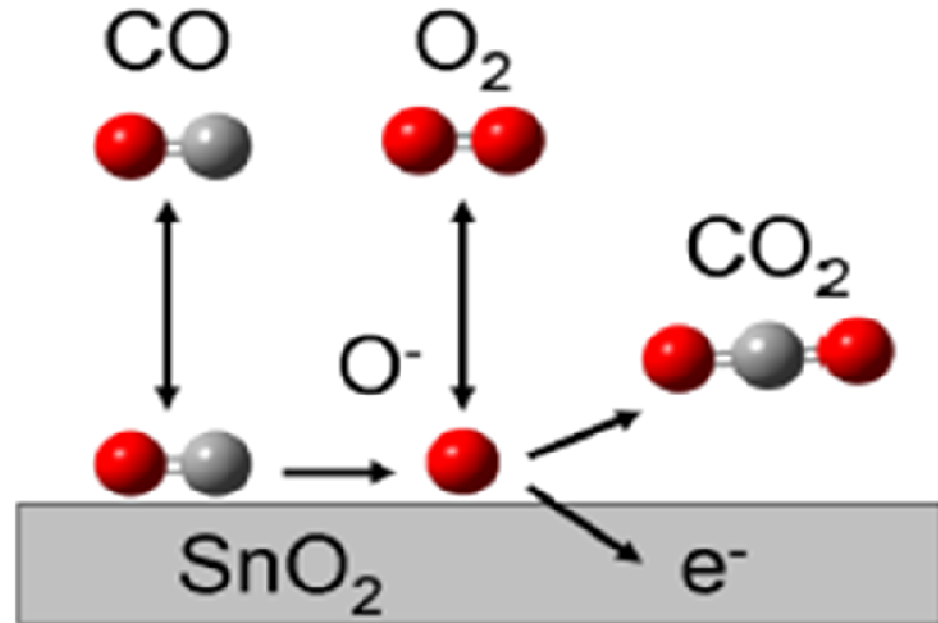
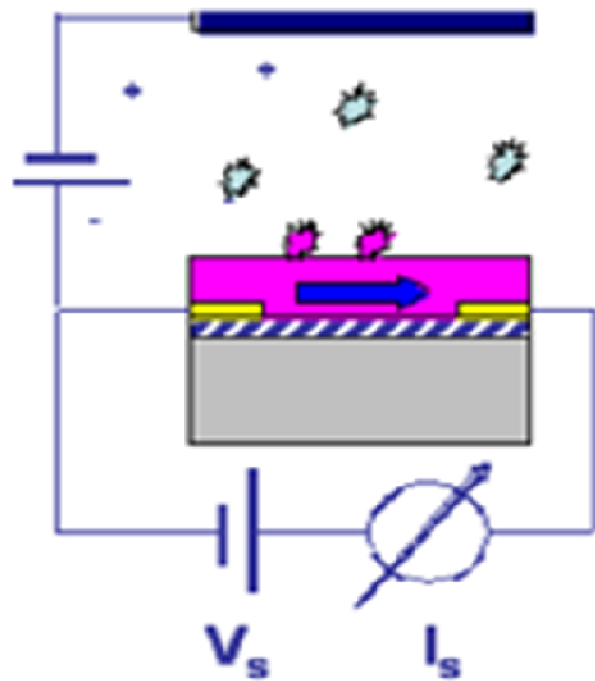
Electrical response (I or V) due to the electrochemistry processes



Scientific context and objectives

- Brief reminder of objectives:

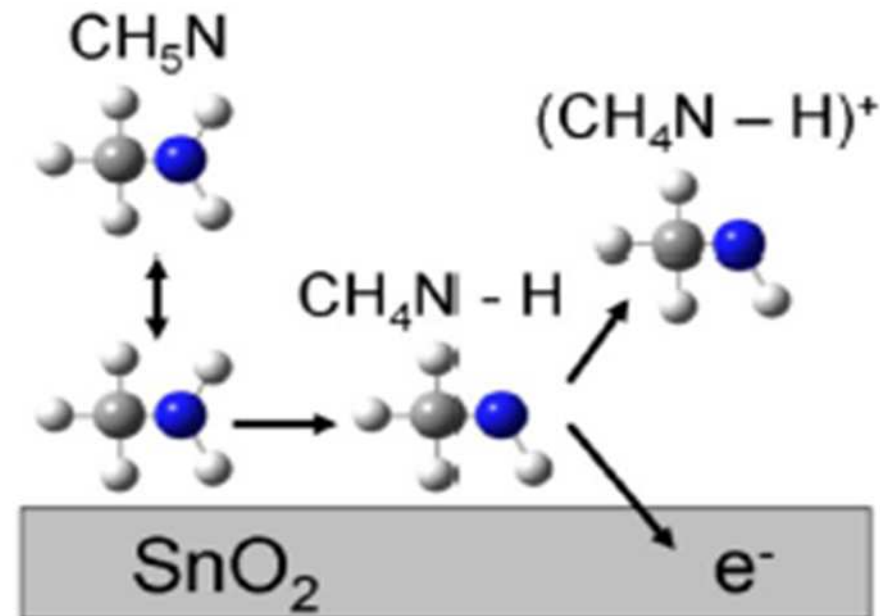
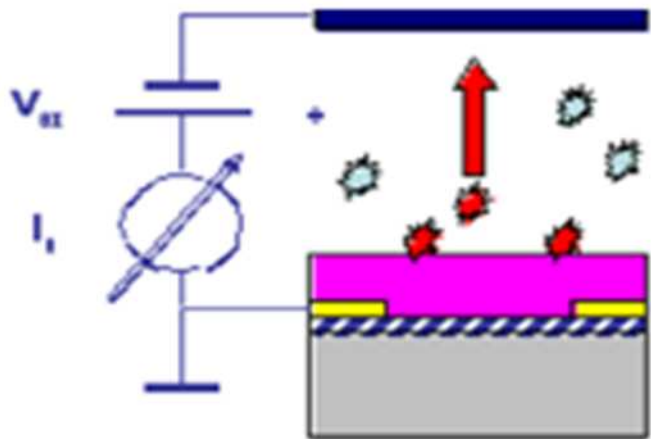
Resistive response due to the surface modifications



Scientific context and objectives

- Brief reminder of objectives:

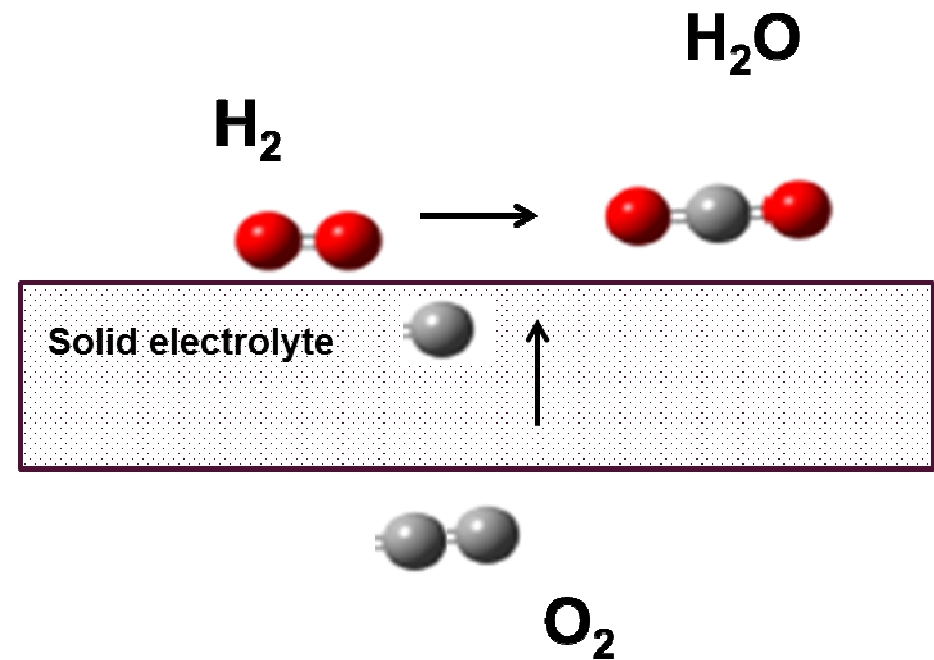
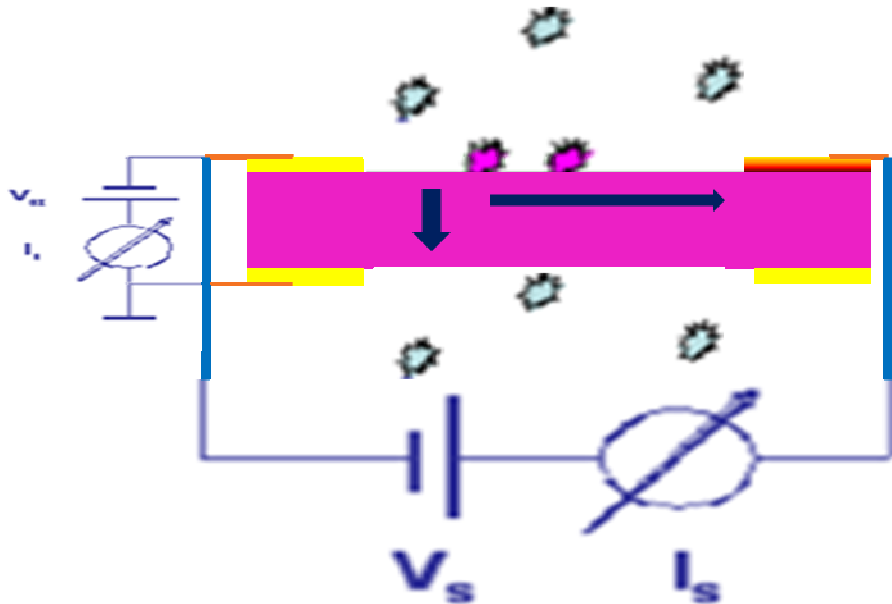
Ionization response due to the surface ionization processes



Scientific context and objectives

- Brief reminder of objectives:

Electrical response (I or V) due to the electrochemistry processes



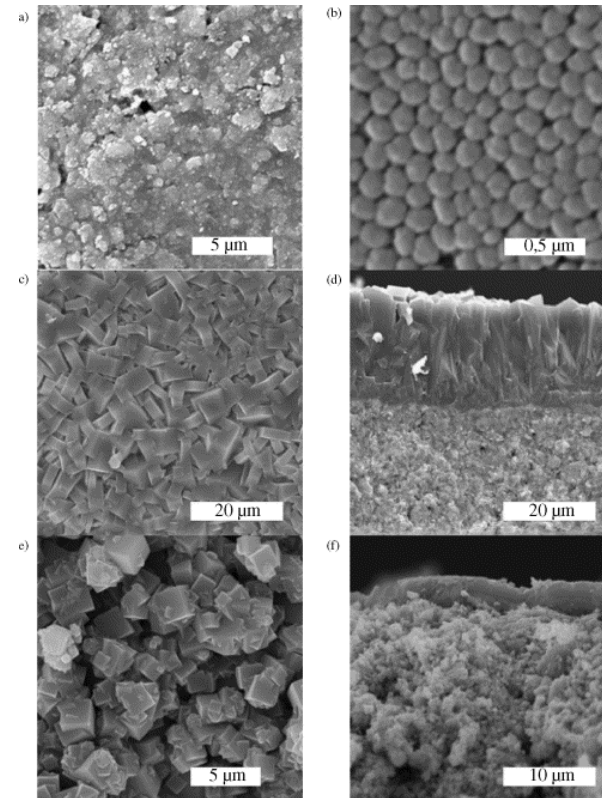
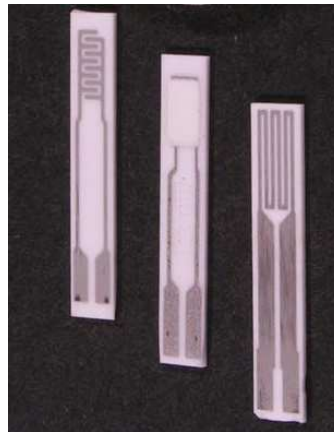
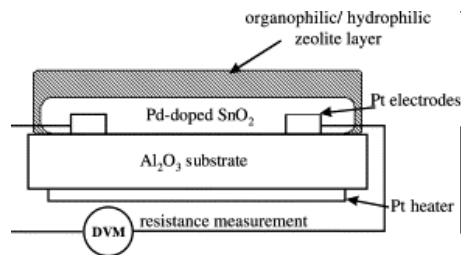


**FULLY INTEGRATED
ALL-SOLID-STATE SENSORS
ON MICROMACHINED PLATFORMS:
NEW TYPE OF GAS SENSORS**
Resistive sensor based on Nanostructures

Scientific context and objectives

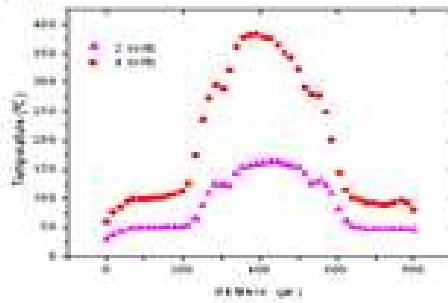
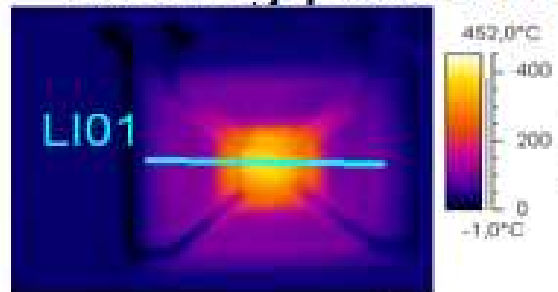
- Brief reminder of objectives:
sensing platforms
Alumina substrates

SNB 31, 1 (1996)
J. Appl. Phys. 90, 1550 (2001)
Catal. Today 82, 179(2003)

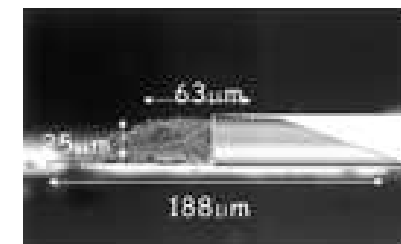
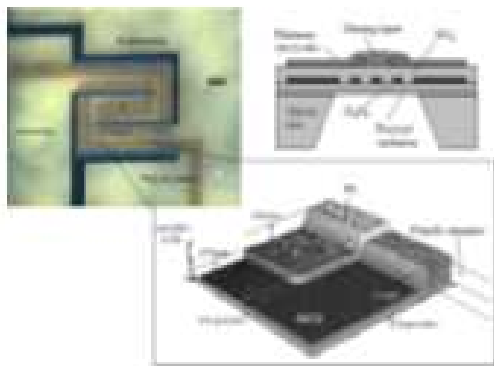
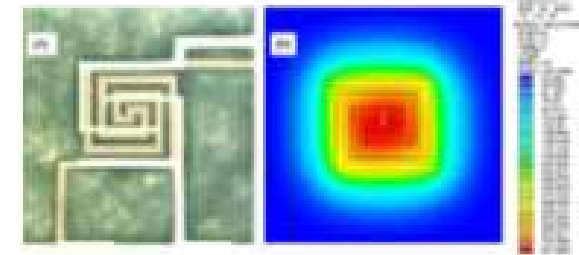
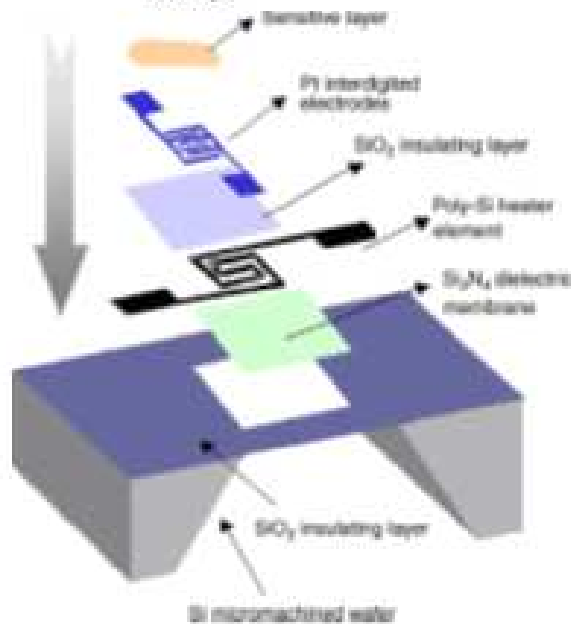
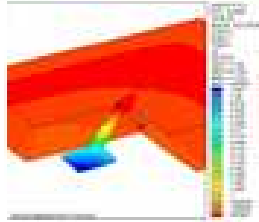


Scientific context and objectives

- Brief reminder of objectives:
sensing platforms

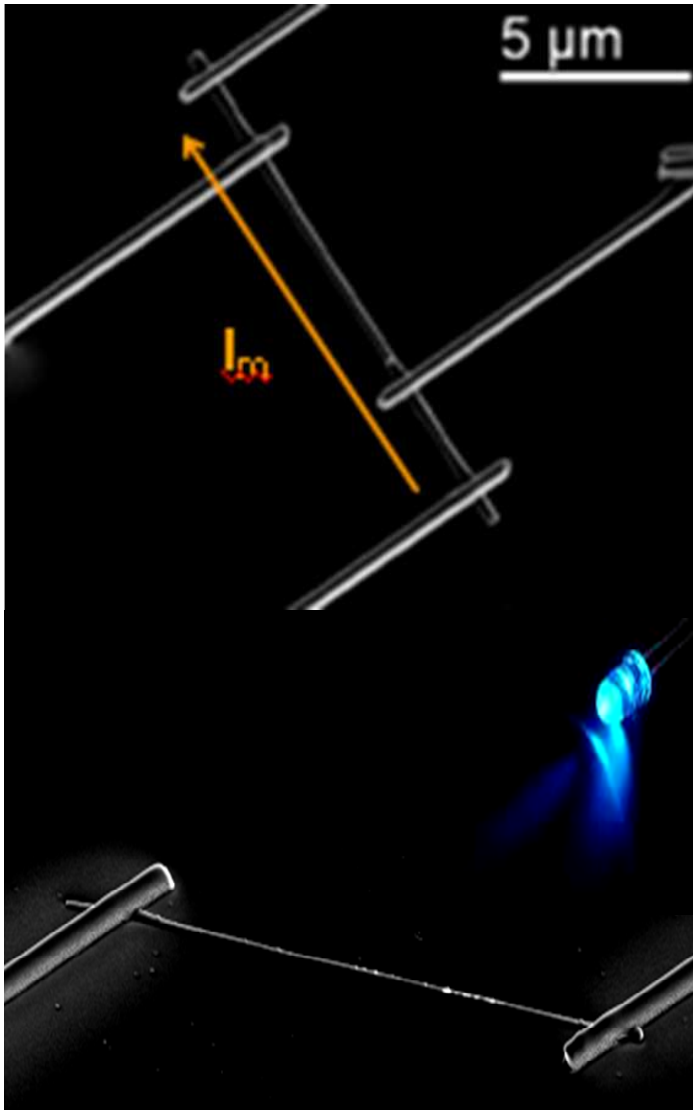


SNB 84, 60 (2002)
SNB 95, 275 (2003)
J. Micromech. Microeng.
13, 5119 (2003)
J. Micromech. Microeng.
13, 548 (2003)
SNB 114, 826 (2006)
SNB 114, 881 (2006)

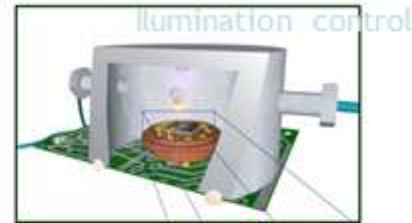


Sensing platforms based on individual nanowires

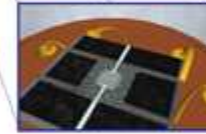
Electrical characterization



Gas sensing experiments



Temperature control



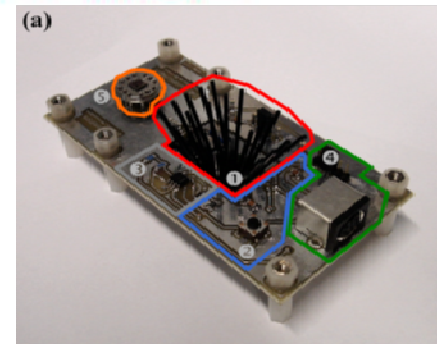
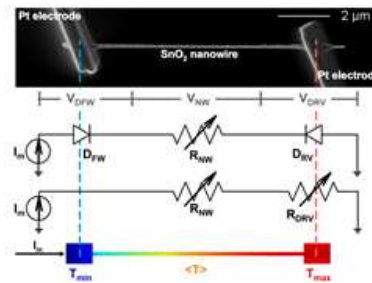
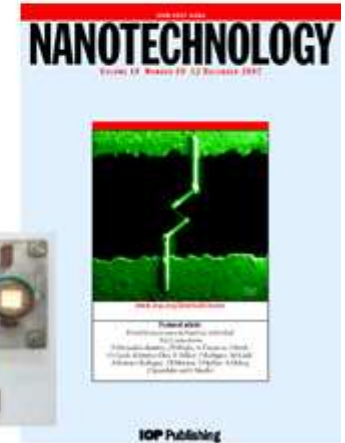
Computer record and analysis

Multiple devices

Nanotechnology 18, 495501 (2007)
mst/news 3/08, 6 (2008)

**“very low power consumption:
less than 20μW (and even less)”**
(measurement AND HEATING included!!!)

APL (2008)

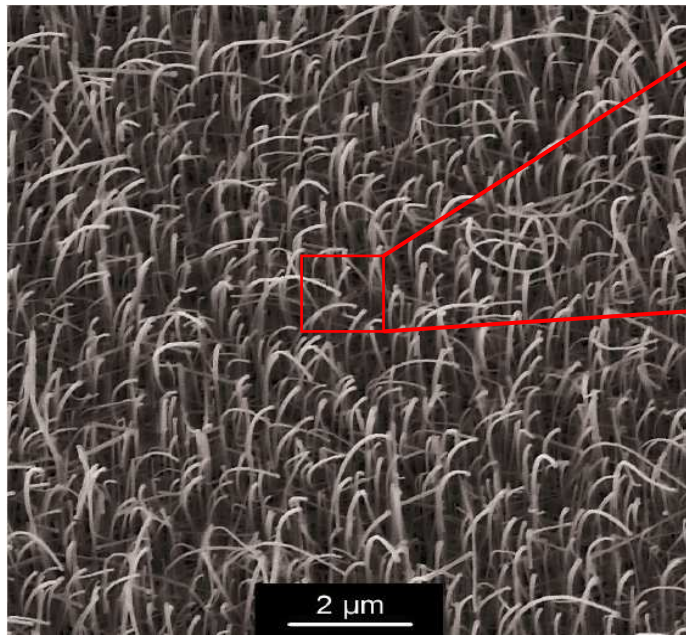


J of PhysChem C (2008)
APL,(2009)
S&A:B (2010,2011)

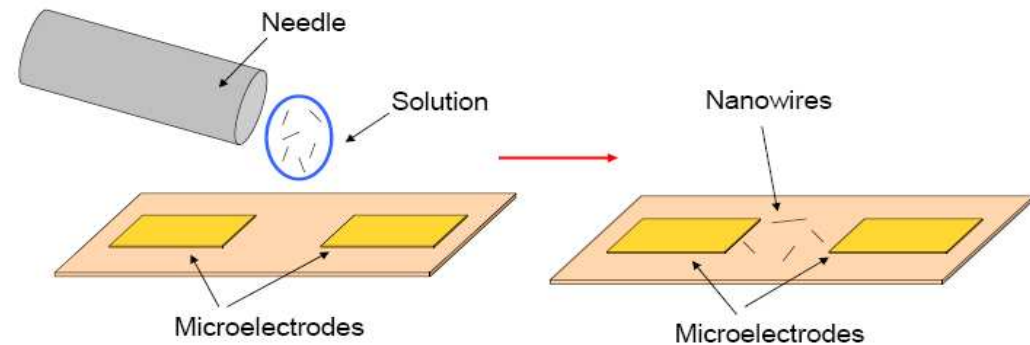
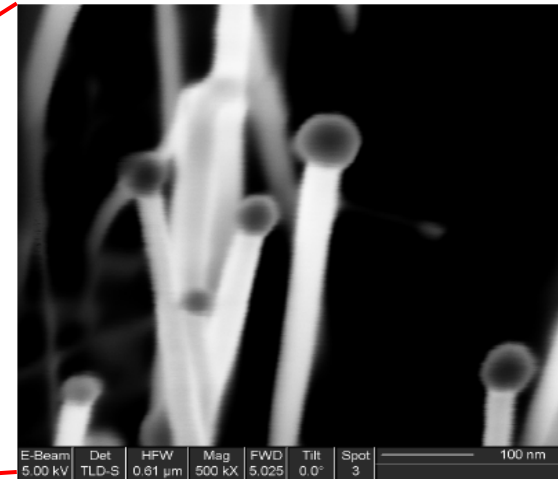
Using individual nanowire as experimental platform

Nanowires are dispersed over a substrate with pre-patterned microelectrodes:

Adv. Funct. Mater. 10.1002/adfm.200701191



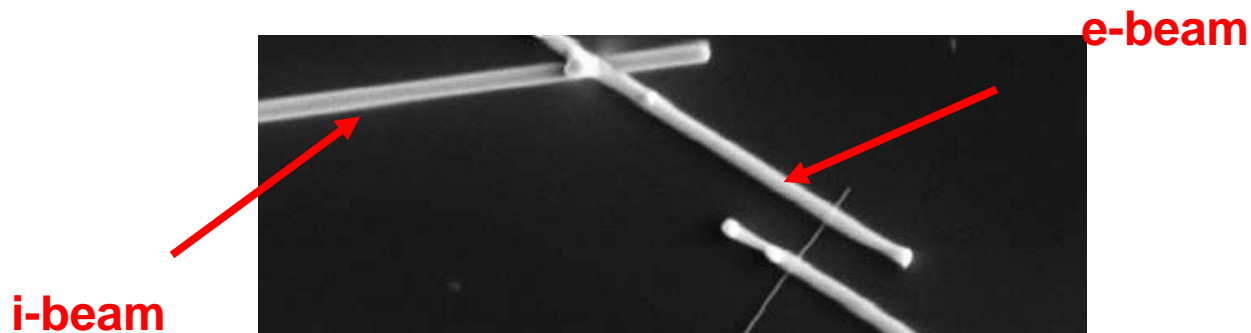
SnO₂ Nanowires



Individual nanowire platforms

Nanofabrication: botom-up approach

- ✓ **Immediate test of novel materials** *Nanotechnology 17, 5577 (2006)*
- ✓ Nanowires contacted with e^- & i^- beam **FIB nanolithography**

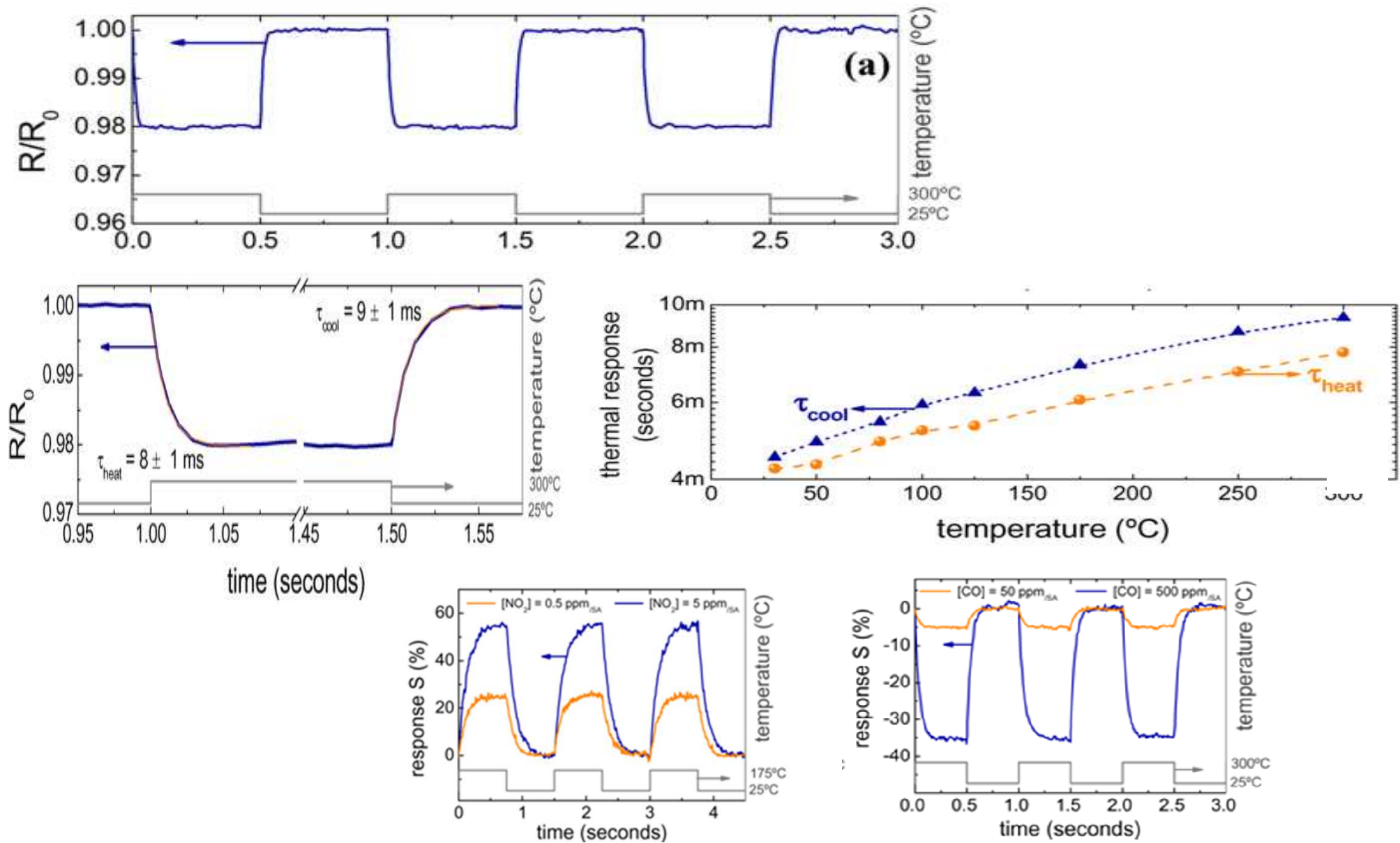


Nanotechnology, 18(49) 2007

Advanced Functional Materials 18,2990-2994,
(2008)

E-Beam	Det	HFW	Mag	FWD	Tilt	Spot	2 μ m
5.00 kV	SED	15.2 μ m	20.0 kX	5.051	0.0°	3	

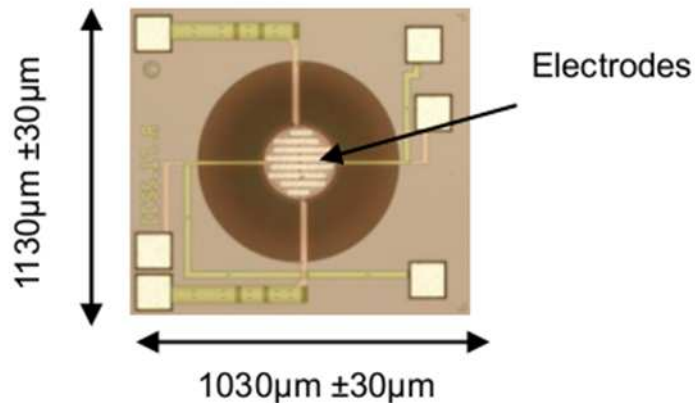
Thermal inertia: thermal time constants versus chemical reactions at the Mox surface



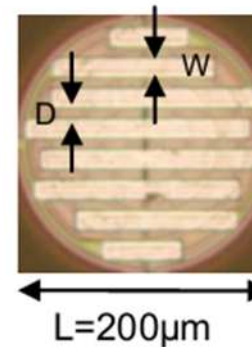
Scientific context and objectives

- Brief reminder of objectives: new performance hotplate for improved gas sensors based on SOI technology

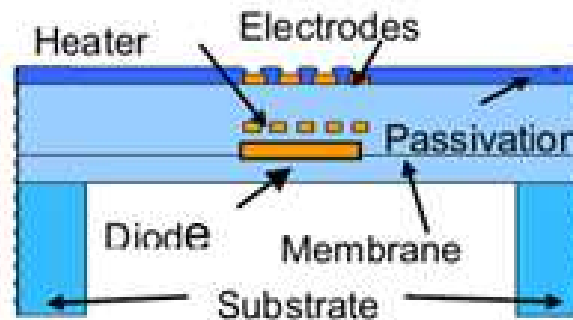
Die Dimension



Electrode Dimension

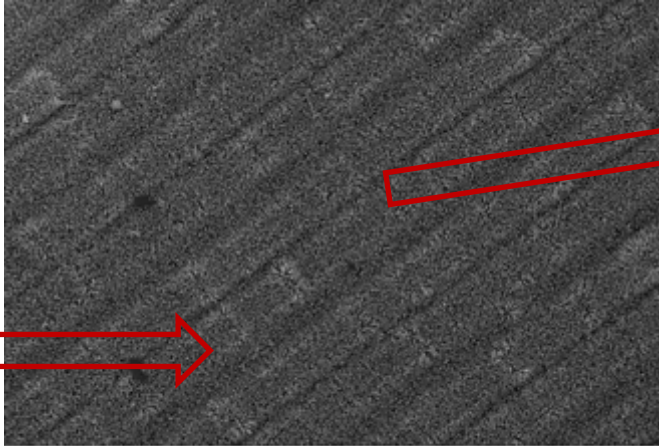
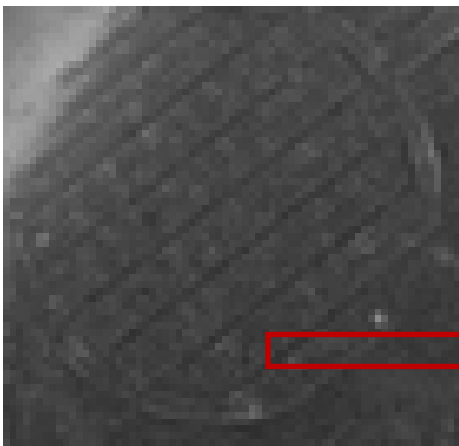


IDE Width (W): $\sim 18\mu\text{m}$
Separation (D): $\sim 8\mu\text{m}$
Electrodes: 2 x 4
Aspect Ratio: ~ 120



7fp ICT:SOI-HIT

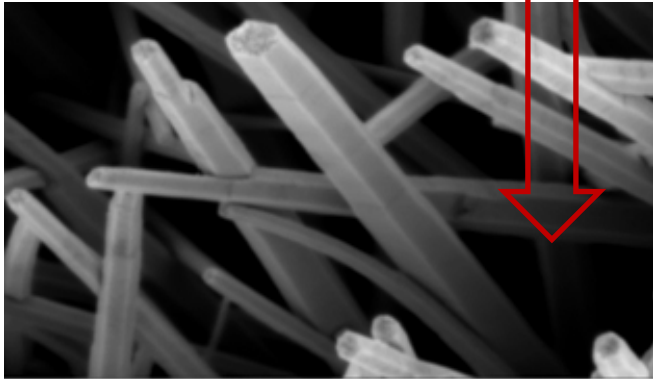
New materials and processes



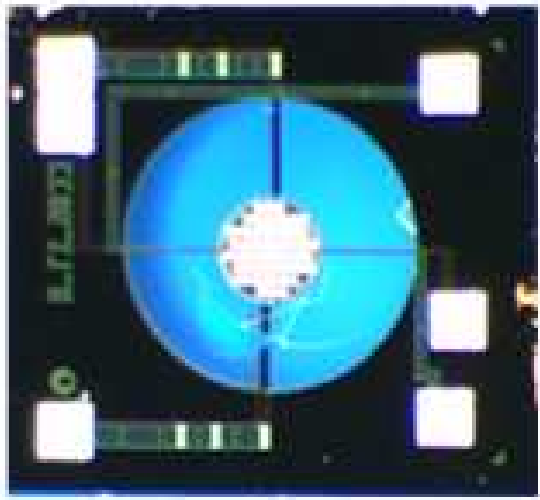
10 μ m EHT = 1.00 kV Signal A = InLens
WD = 3.5 mm Mag = 840 X
19 Jul 2012 ZEISS



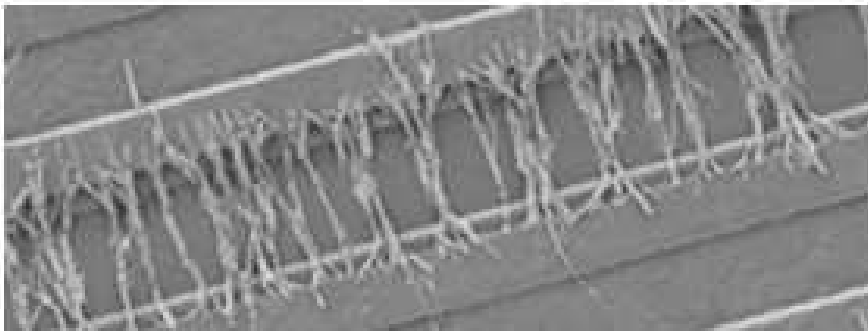
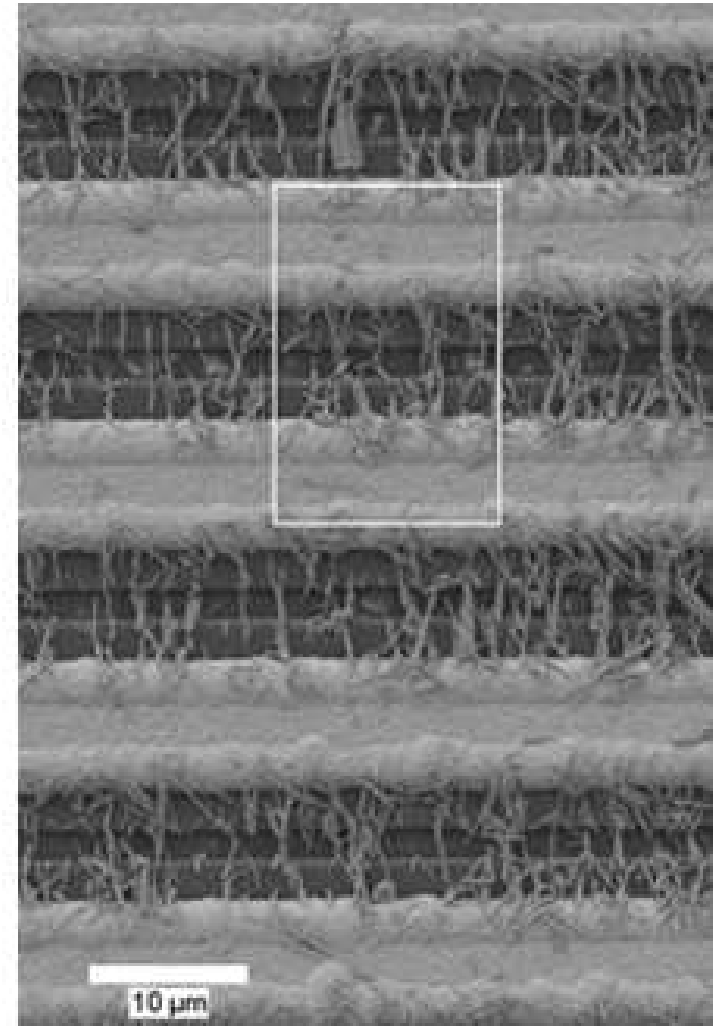
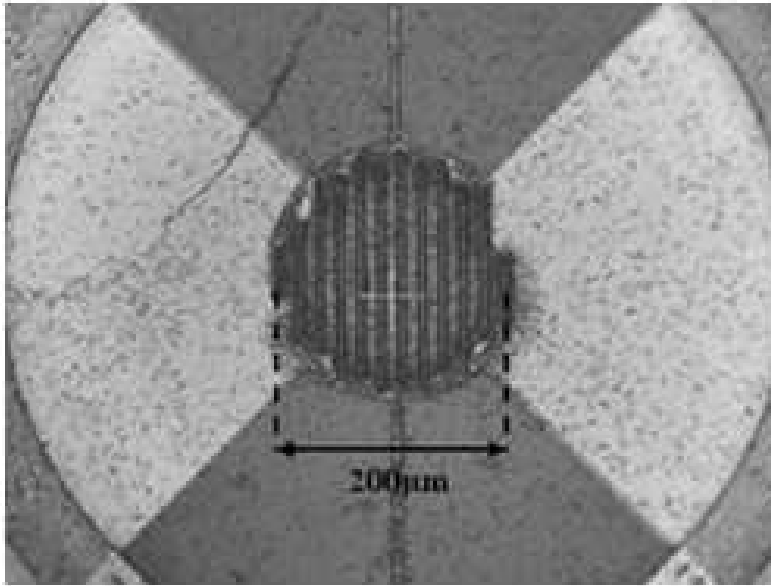
1 μ m EHT = 1.00 kV Signal A = InLens
WD = 3.5 mm Mag = 10.00 K X
19 Jul 2012 ZEISS



100 nm EHT = 1.00 kV Signal A = InLens
WD = 3.5 mm Mag = 80.84 K X
19 Jul 2012 ZEISS

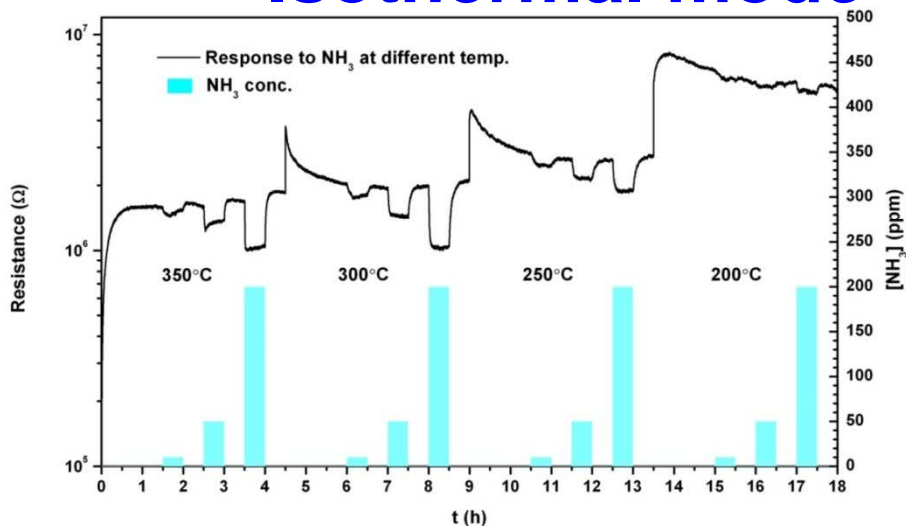


New materials and processes

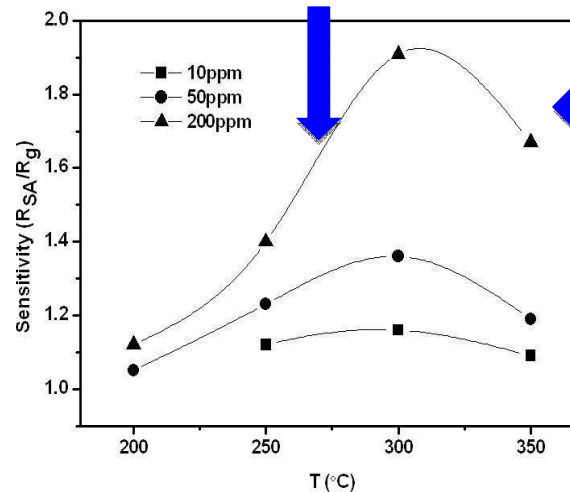


New materials and processes

Isothermal mode

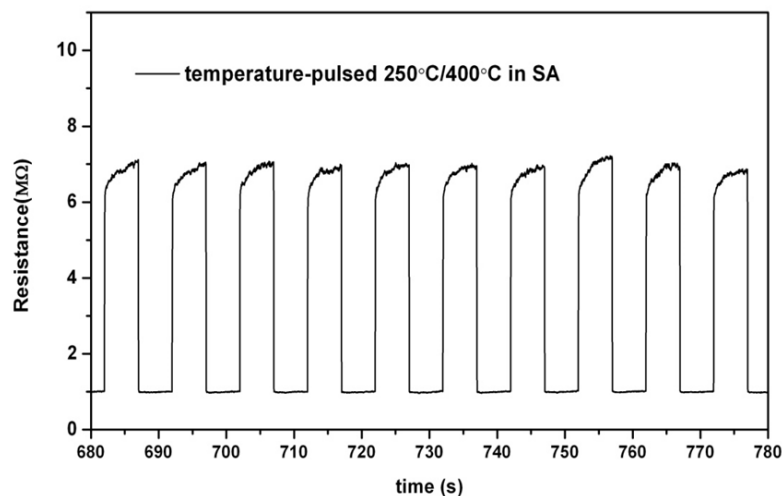


Surface reactivity



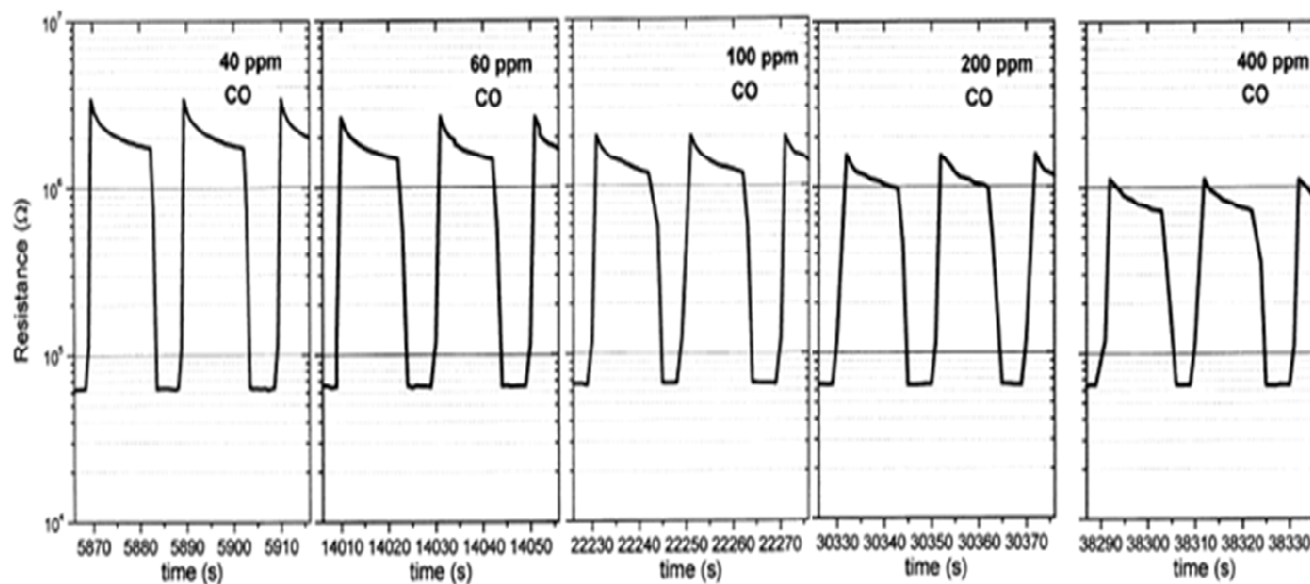
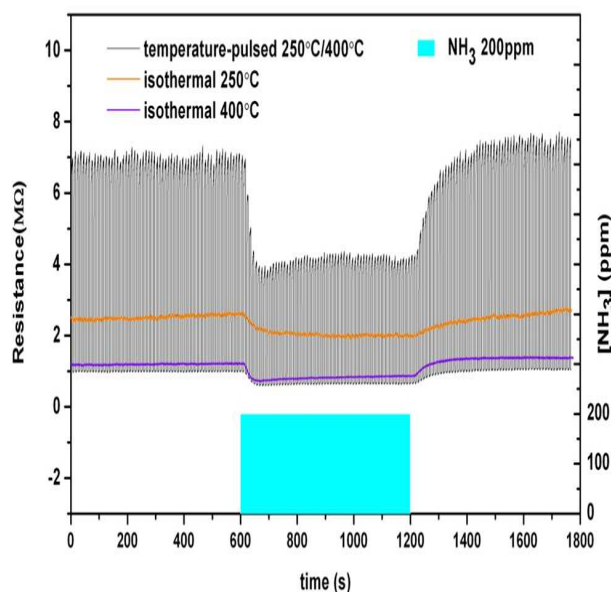
Surface desorption


Pulsed mode



New materials and processes

Improving sensing due to the pulsed mode:
stimulating sensing surface at high temperature and
freezing sensing conditions at low temperature

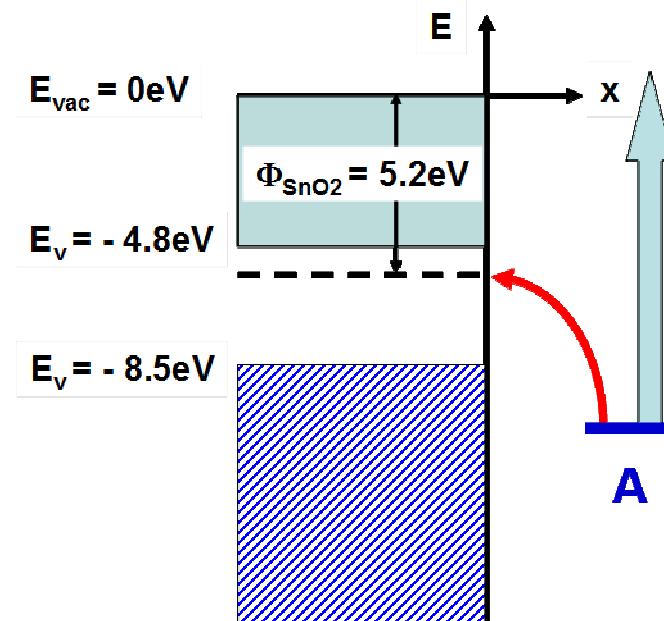
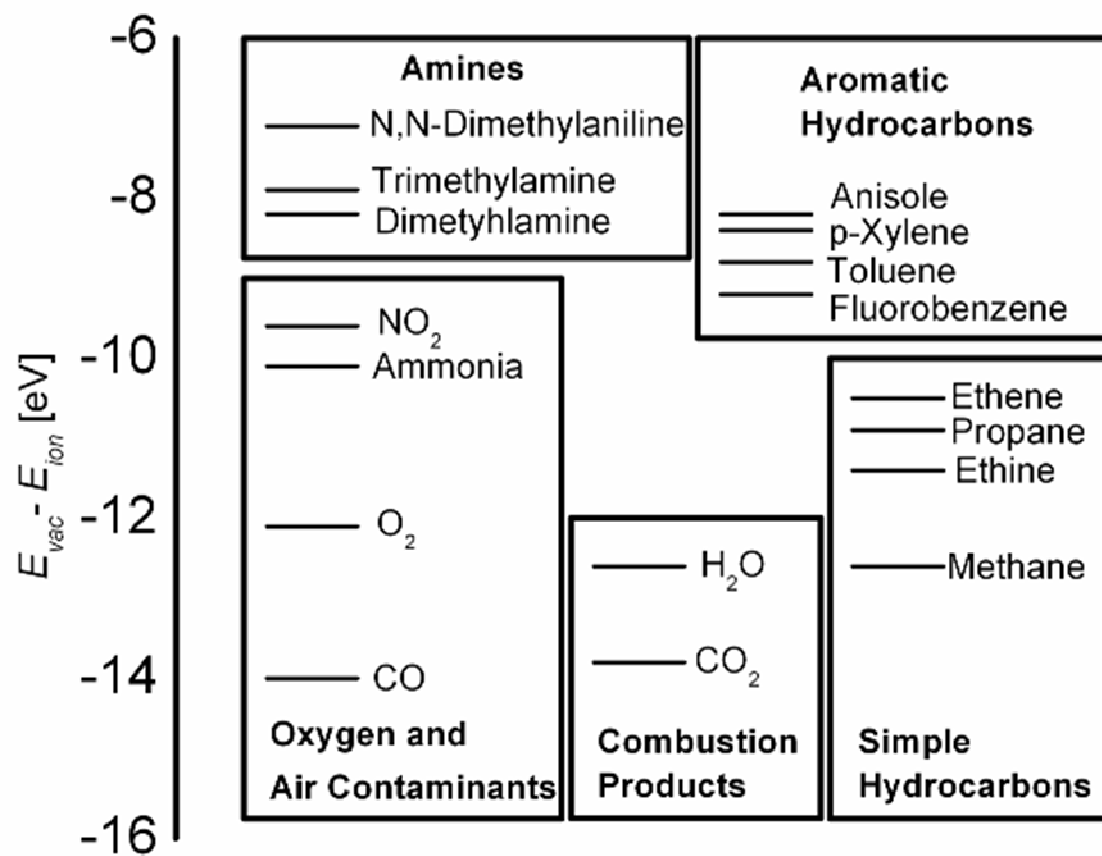


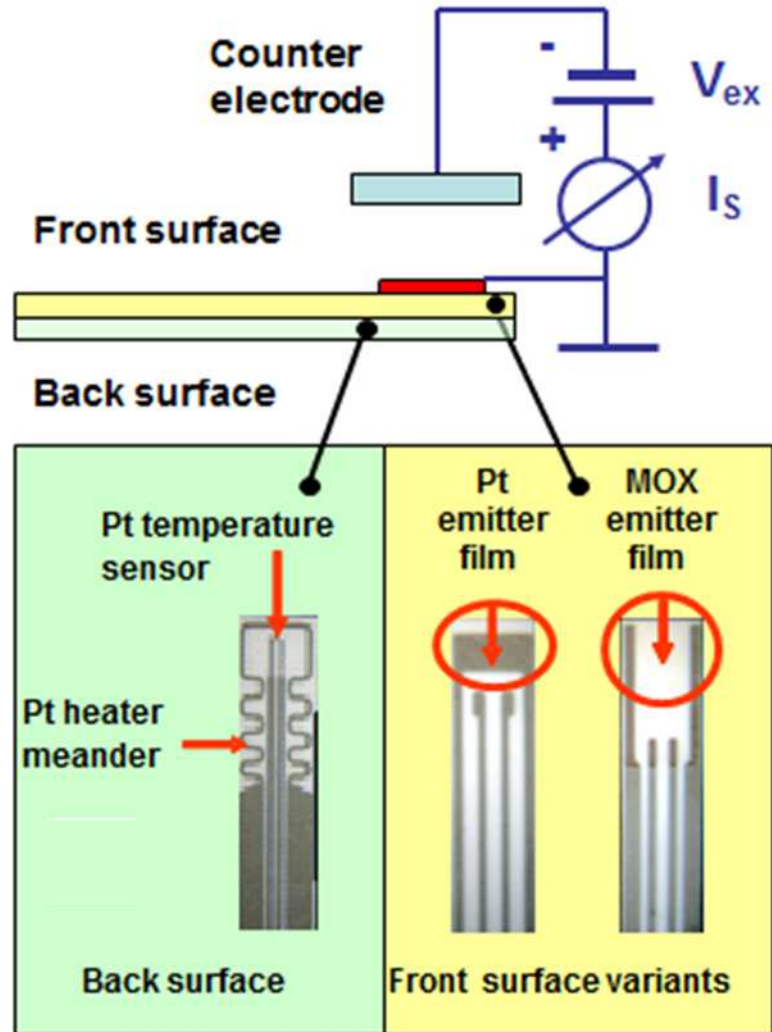


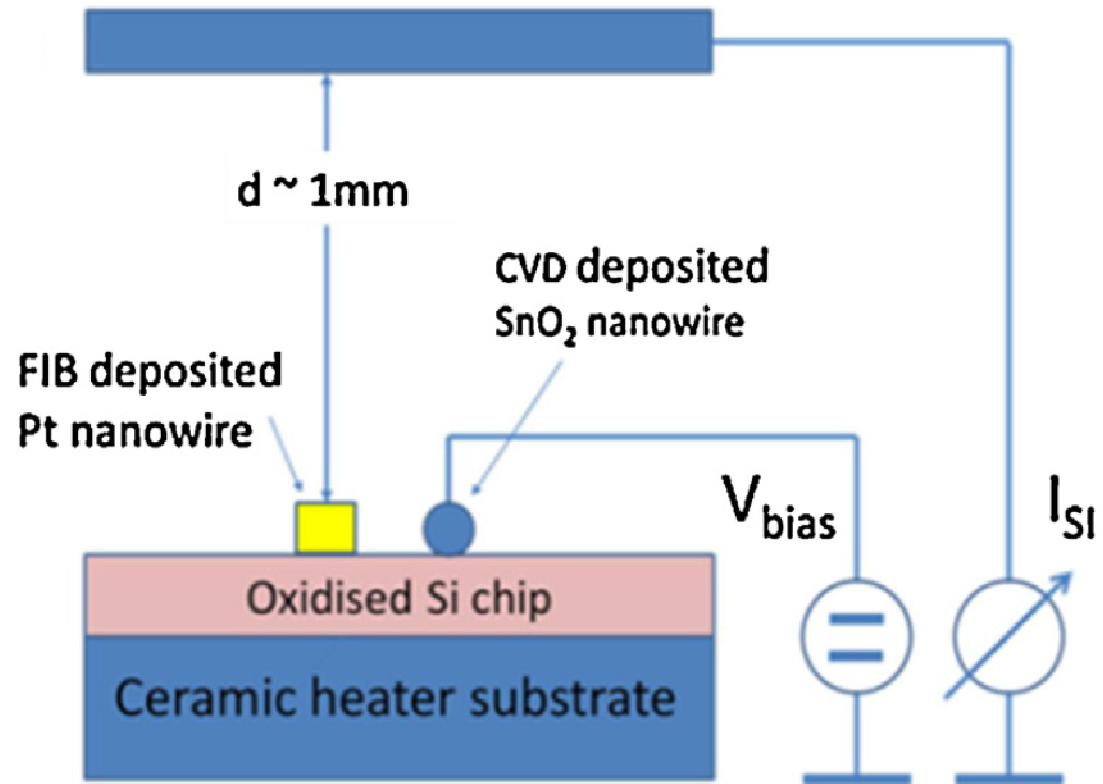
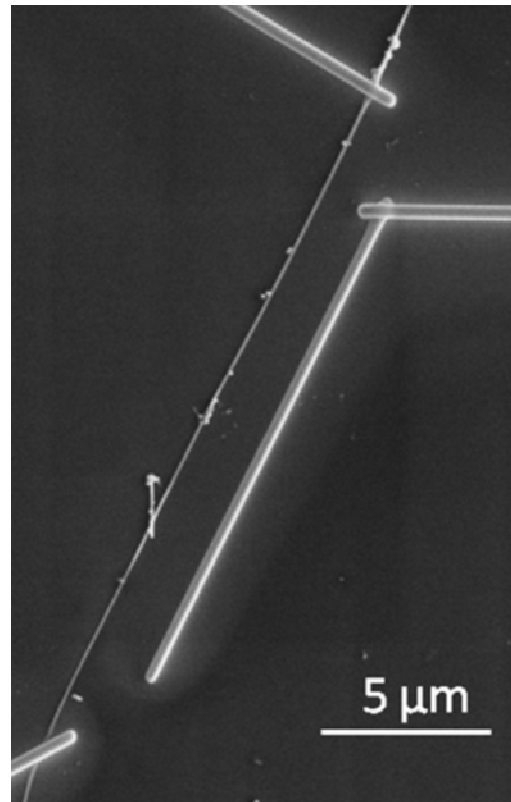
FULLY INTEGRATED ALL-SOLID-STATE SENSORS ON MICROMACHINED PLATFORMS: NEW TYPE OF GAS SENSORS

Surface ionization based on nanostructures

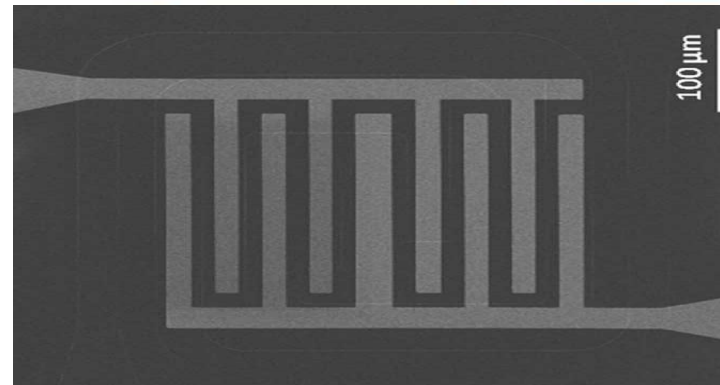
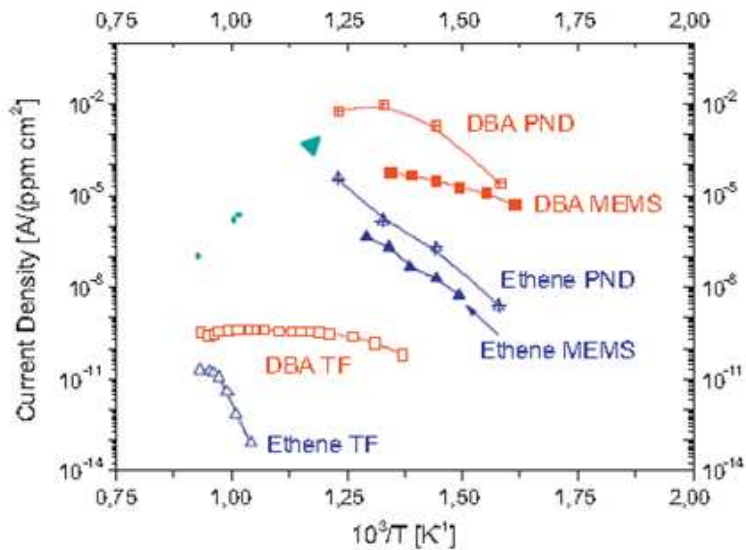
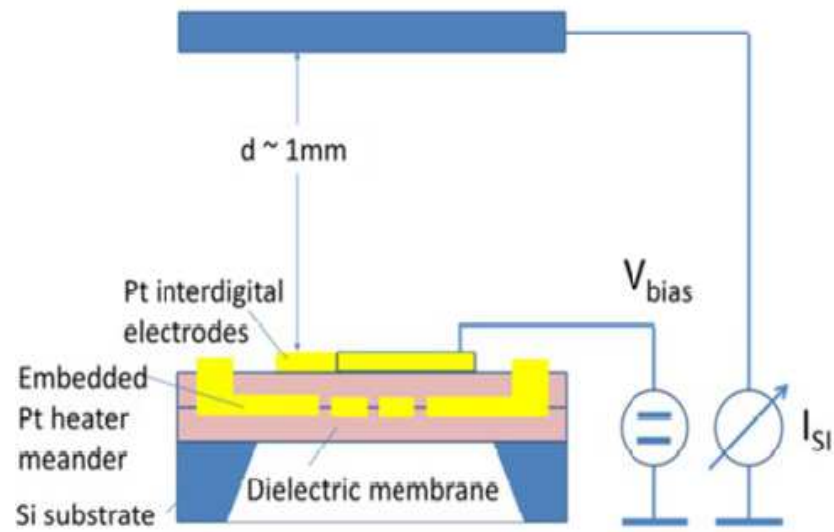
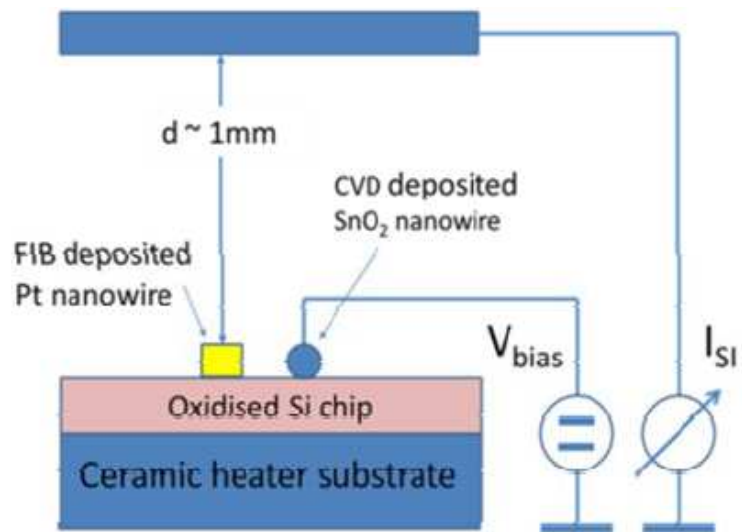
7FP NMP S3







(a) top view onto the parallel nanowire (PNW) chip investigated; (b) vertical readout mode applied to the PNW chip in (a) turning it into a single nanowire (SNW) device. In both modes of readout the PND chip is glued to a ceramic heater substrate carrying a Pt heater meander and a Pt thermometer on its backside

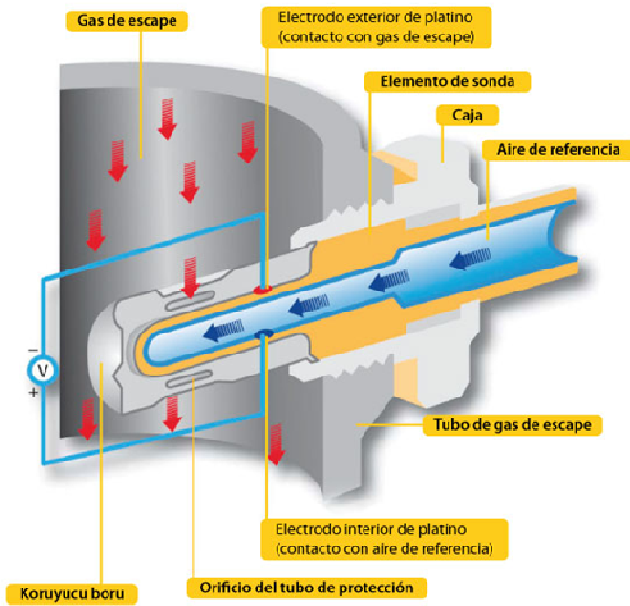
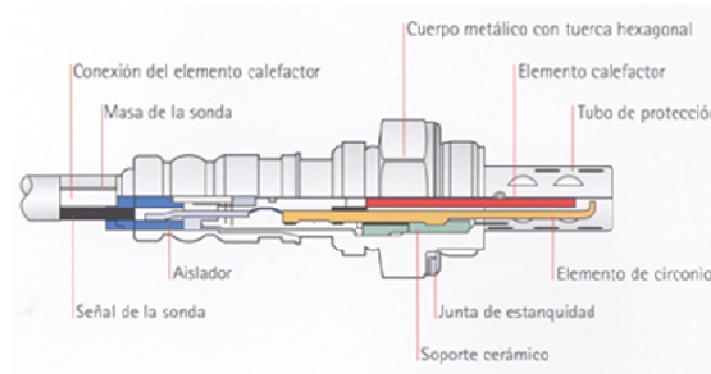


Specific SI emission currents for analytes with different free-space ionization energy EI: DBA (EI = 7.5 eV) and ethene (EI = 10.5 eV) as observed in MEMS, PNDs and TF devices.

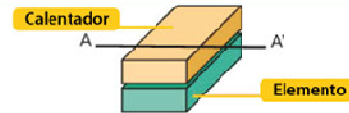


FULLY INTEGRATED ALL-SOLID-STATE SENSORS ON MICROMACHINED PLATFORMS: NEW TYPE OF GAS SENSORS

Electrochemical sensors based on nanoionics



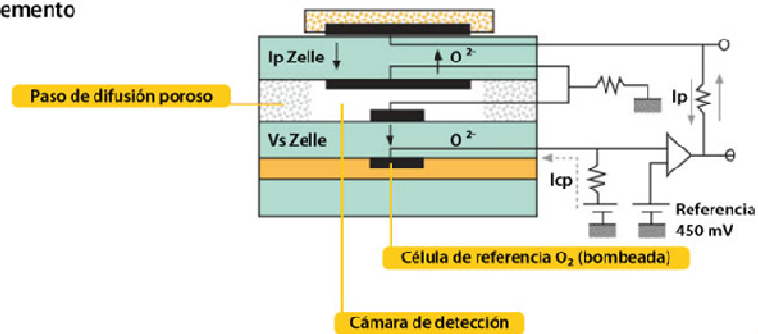
Vista A-A'



Calentador



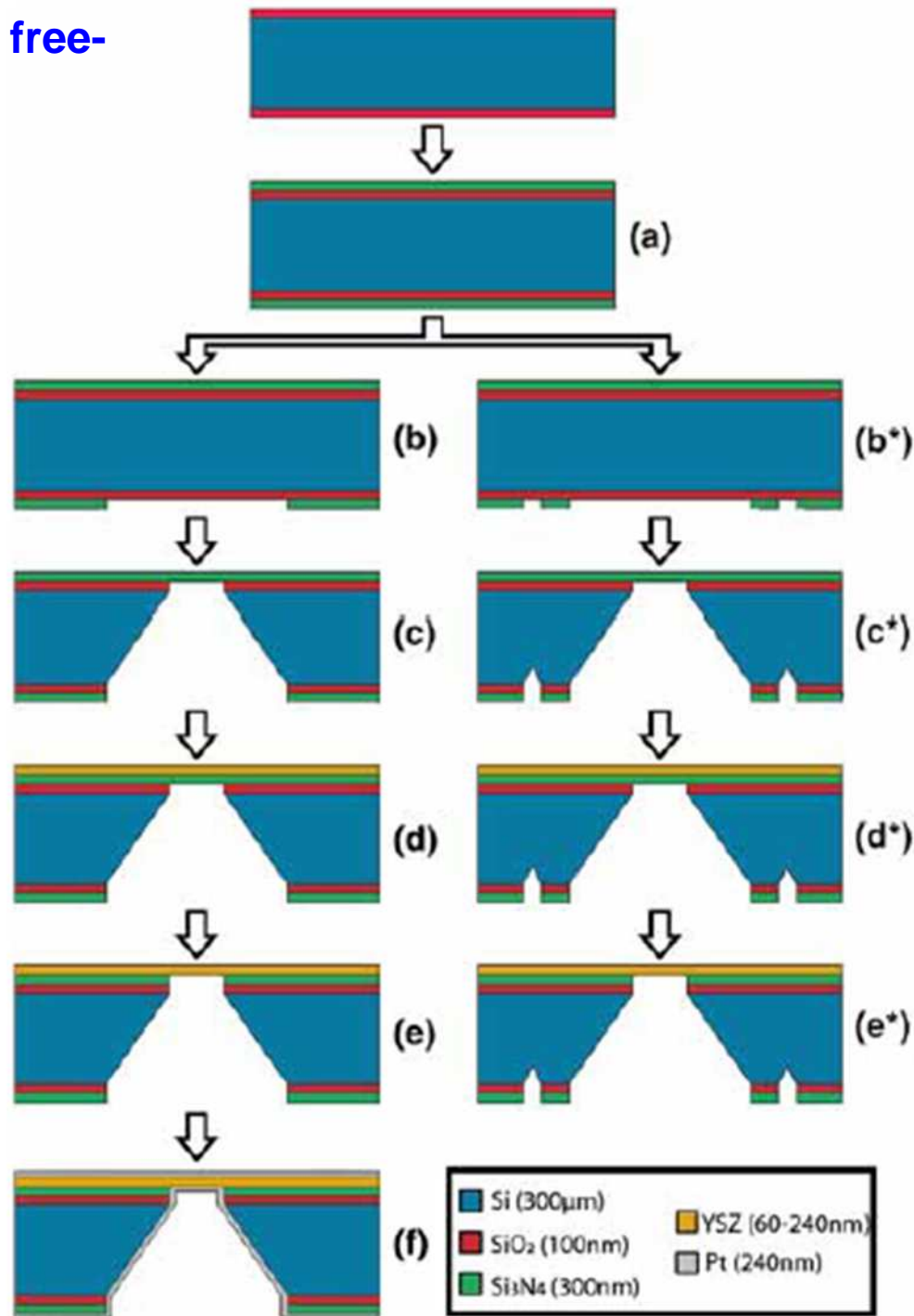
Elemento

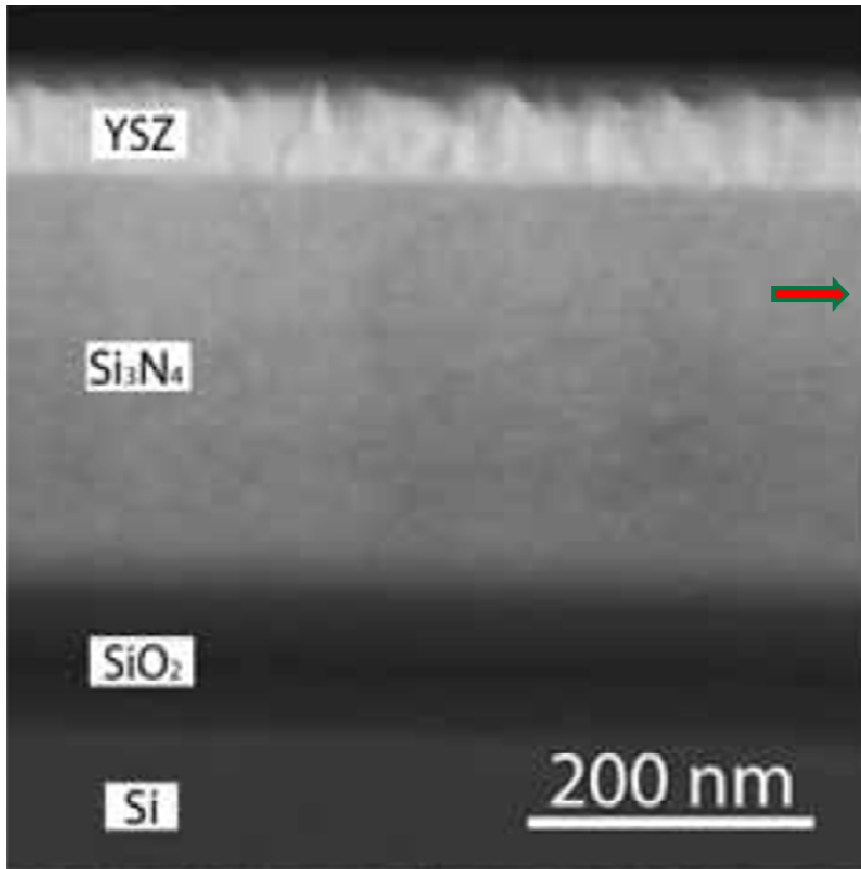


Fabrication process of YSZ free-standing membranes:

deposition of 300 nm Si₃N₄ on both sides of a 300 μm thick silicon wafer
 100-nm thermally oxidized;
 back side photolithography and silicon nitride dry etching;
 silicon oxide and silicon wet etching with HF and KOH, respectively;
 deposition of 120 nm YSZ thin layer by PLD;
 creation of the self-supported YSZ membrane with a silicon nitride reactive ion etching from the back-side;
 deposition of 240 nm Pt layer or electrodes by sputtering.

Parallel steps (marked with stars) refer to the alternative fabrication flow used for membranes compatible with TEM sample holders.

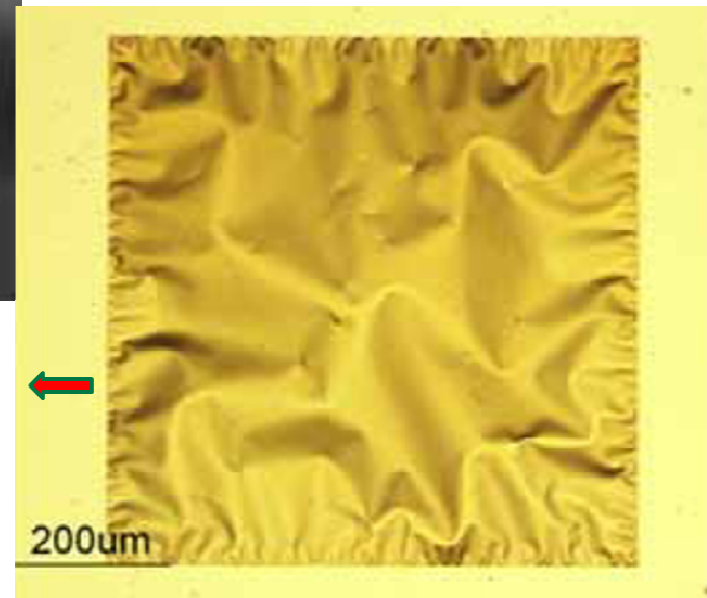


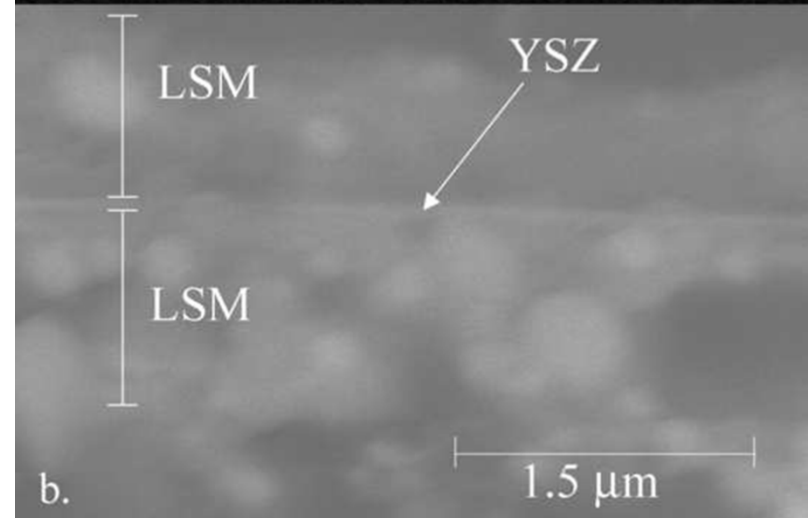
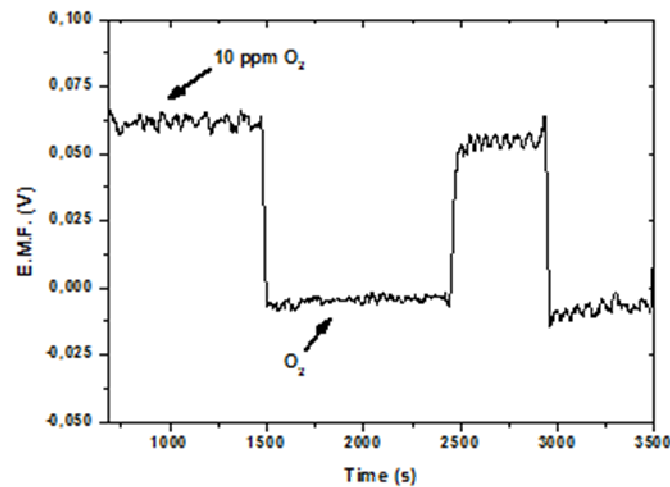
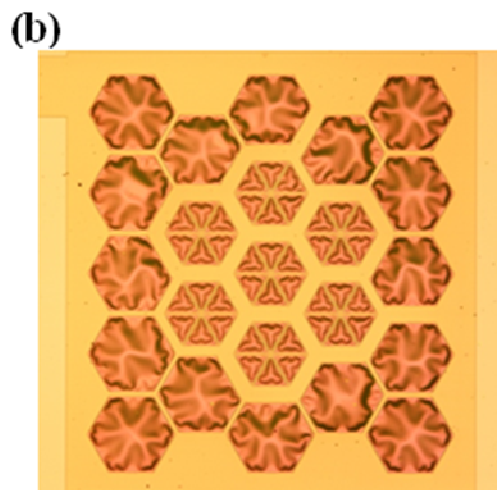
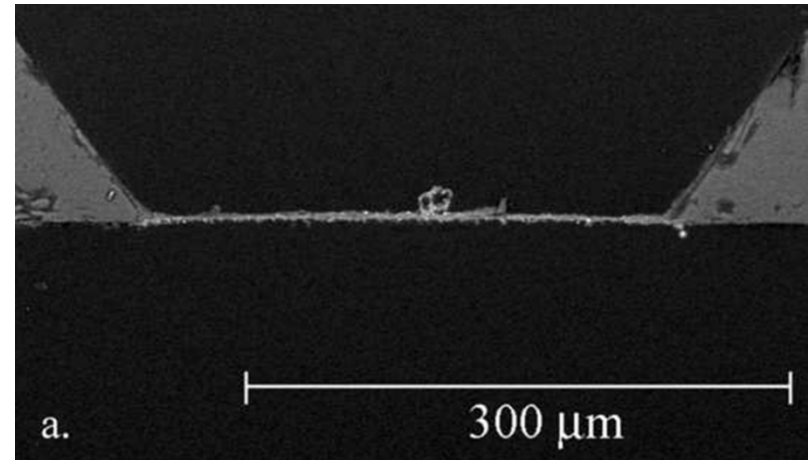
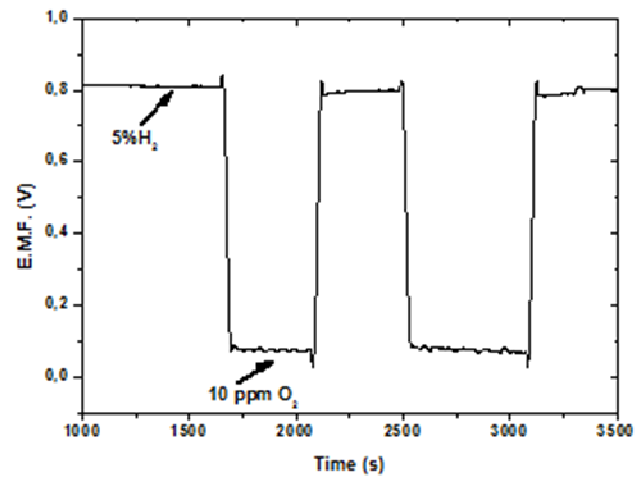
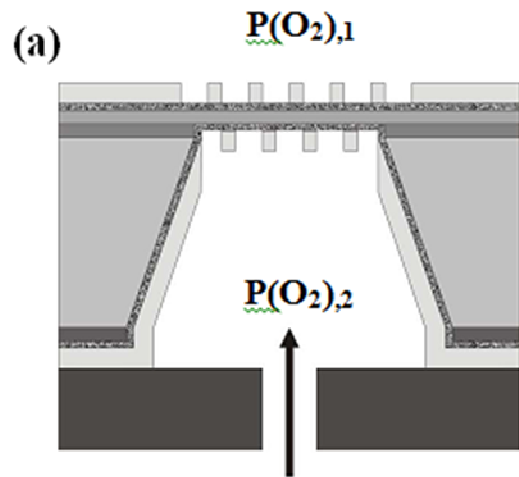


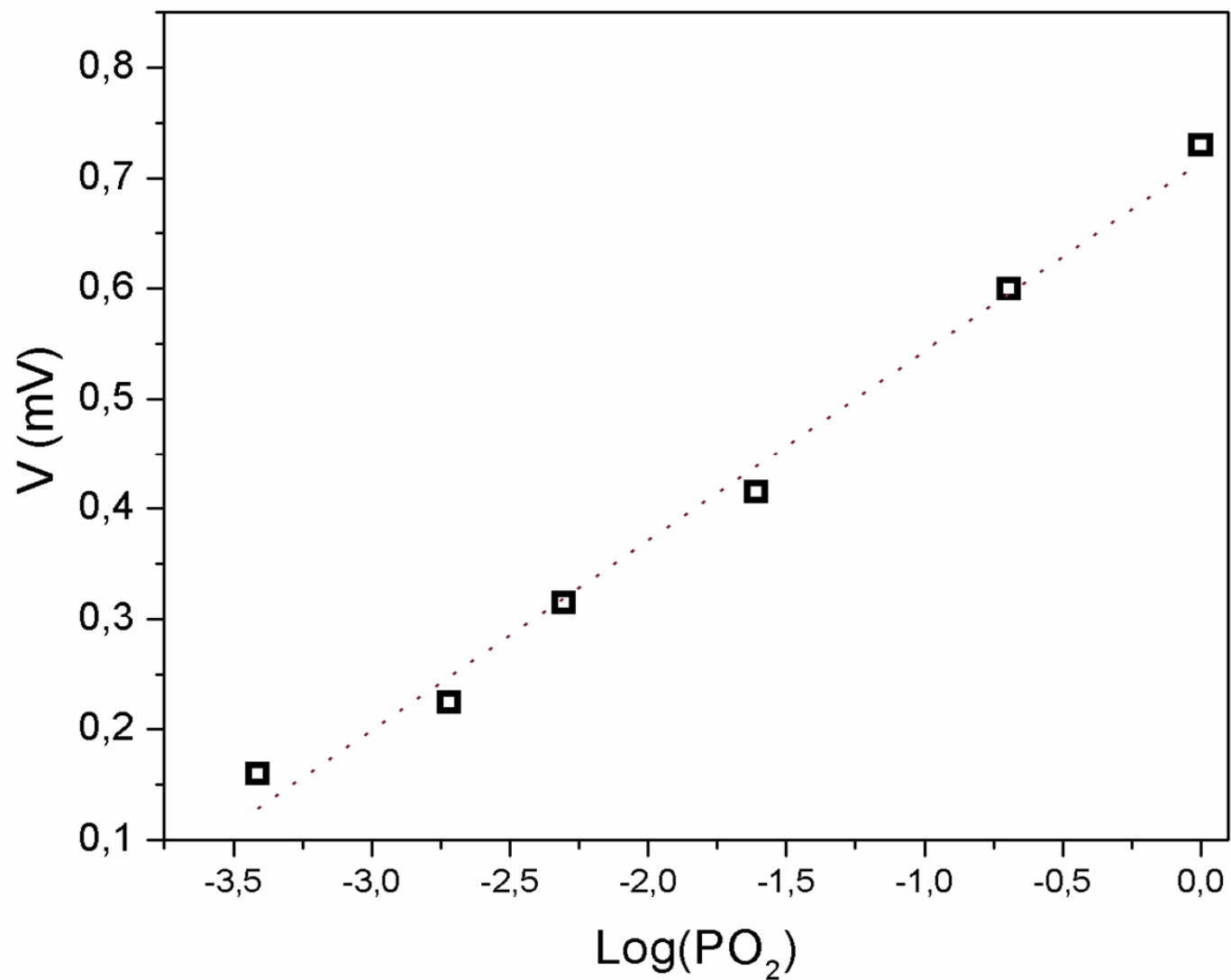
Cross-section SEM image of a 60 nm thick YSZ layer deposited by PLD at 200 °C.


The YSZ layers were deposited on Si/SiO₂/Si₃N₄ substrates.

Optical microscope top view image of a typical free-standing YSZ membrane









Micro and Nanotechnology are changing the perspective in the field of integrated gas sensors:

Conductometric gas sensors based on nanostructures growth or deposited on hotplates open new pathways.

Surface ionization is also improving performances due to the temperature and field effects at the nano scale level defined by nanostructures managed by high temperature hot plates.

Fully integrated electrochemical gas sensors based on nanoionics characteristics of the a thin solid electrolyte layer and its control based on high temperature hot plate are also changing the future in this field.

RESULTS and future activities

- Micro and Nanotechnology are changing the perspective in the field of integrated gas sensors
- Conductometric gas sensors based on nanostructures growth or deposited on hotplates open new pathways.
- Surface ionization is also improving performances due to the temperature and field effects at the nano scale level defined by nanostructures managed by high temperature hot plates.
- Fully integrated electrochemical gas sensors based on nanoionics characteristics of the a thin solid electrolyte layer and its control based on high temperature hot plate are also changing the future in this field.

Future planned **Activities**

- Pulsed mode operation instead isothermal working mode improves the characteristics of conductometric gas sensors, as non expensive devices. Selectivity and sensor response are improved allowing better measurement of CO, NH₃, NO_x,
- Surface ionization based sensors improve also selectivity
- Fully integrated electrochemical are very promising Pat. N^o P26999ES01

All these new options need to be explored to evaluate the full feasibility of these new approaches

CONCLUSIONS

- Micro and Nano technology open new alternatives based on the use of high temperature hotplates.
- Low cost fully integrated all solid state integrated gas sensors based on metal oxides but using different sensing mechanisms
conductometric
surface ionization
electrochemical
are potential candidate as air quality monitoring elements.
- Likewise, these new technological approaches open new sensing operation modes, due to the very short response time of these systems. Moreover their combination allows the application of new algorithms improving the discrimination between interfering gases for a better air quality assessment and monitoring.